

Nelson Felix

List of Publications by Year in descending order

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Version: 2024-02-01

7
papers

318
citations

1684188

5
h-index

1872680

6
g-index

7
all docs

7
docs citations

7
times ranked

436
citing authors

| # | ARTICLE | IF | CITATIONS |
|---|---|------|-----------|
| 1 | Molecular Glass Resists for High-Resolution Patterning. Chemistry of Materials, 2006, 18, 3404-3411. | 6.7 | 104 |
| 2 | Directed self-assembly of block copolymers for 7 nanometre FinFET technology and beyond. Nature Electronics, 2018, 1, 562-569. | 26.0 | 87 |
| 3 | Sub-50 nm feature sizes using positive tone molecular glass resists for EUV lithography. Journal of Materials Chemistry, 2006, 16, 1470. | 6.7 | 83 |
| 4 | Phenolic molecular glasses as resists for next-generation lithography. , 2007, 6519, 1291. | | 24 |
| 5 | New PFOS Free Photoresist Systems for EUV Lithography. Journal of Photopolymer Science and Technology = [Fotoporima Konwakai Shi], 2006, 19, 515-520. | 0.3 | 8 |
| 6 | Molecular glass resists for next generation lithography. Proceedings of SPIE, 2008, , . | 0.8 | 6 |
| 7 | DSA patterning options for FinFET formation at 7nm node. Proceedings of SPIE, 2016, , . | 0.8 | 6 |